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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicants : Chandra V. Mouli and Ceredig Roberts

Serial No. : 09/648,044

Filed : August 25, 2000

Confirm. No. : 6800

Title : METHOD AND DEVICE TO REDUCE GATE-INDUCED DRAIN  
LEAKAGE (GIDL) CURRENT IN THIN GATE OXIDE MOSFETs

Docket No. : MIO 0054 PA

Examiner : O. Nadav

Art Unit : 2811

**MAIL STOP AMENDMENT**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

**EFS WEB ELECTRONIC SUBMISSION**

**January 16, 2007**

**/William A. Jividen/**

**Reg. No. 42,695**

Sir:

**AMENDMENT**

This paper is being filed in response to the Office Action mailed October 20, 2006.  
Reconsideration is respectfully requested in light of the amendments and remarks below.